## **Supporting Imformation**

## Study into interface engineering and chemical bond of the ReS<sub>2</sub>@ZnO Heterointerface for efficient charge transfer and nonlinear optical conversion efficiency

## Xin-Yu Zheng<sup>1</sup>, Hong-Yu Li<sup>1</sup>, Bing-Yin Shi<sup>1</sup>, Hong-Xu Cao<sup>1</sup>, Yu Liu<sup>1</sup>, and Hai-Tao Yin<sup>1,\*</sup>

<sup>1</sup>Key Laboratory of Photonic and electric Bandgap materials, Ministry of Education, School of Physics and Electronic Engineering, Harbin Normal University, Harbin, 150025, Heilongjiang Province, China \*Corresponding author: wlyht@126.com



Fig. S1. SEM images of ZnO and ReS<sub>2</sub>@ZnO at different condition: a<sub>i</sub>) ZnO-80°C, a<sub>ii</sub>) ZnO-215°C, a<sub>iii</sub>) ZnO-215°C, b<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-80°C, b<sub>ii</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, b<sub>i</sub>) ReS<sub>2</sub>-

 $0.2 mmol @ZnO-350^{\circ}C, c_i) \ ReS_2-0.4 mmol @ZnO-80^{\circ}C, c_{ii}) \ ReS_2-0.4 mmol @ZnO-215^{\circ}C, c_i) \ ReS_2-0.4 mmo$ 

0.4mmol@ZnO-350°C.



Fig. S2. EDS images of (a<sub>i</sub>) ReS<sub>2</sub>-0.2mmol, (a<sub>ii</sub>) ReS<sub>2</sub>-0.3mmol, (a<sub>iii</sub>) ReS<sub>2</sub>-0.4mmol, (b<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-80°C, (b<sub>ii</sub>) ReS<sub>2</sub>-0.3mmol@ZnO-80°C, (b<sub>ii</sub>) ReS<sub>2</sub>-0.4mmol@ZnO-80°C, (c<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, (b<sub>ii</sub>) ReS<sub>2</sub>-0.3mmol@ZnO-215°C, (b<sub>iii</sub>) ReS<sub>2</sub>-0.4mmol@ZnO-215°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.3mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.4mmol@ZnO-350°C, (e<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-350°C, (e<sub>i</sub>) ReS<sub>2</sub>-0.3mmol@ZnO-350°C, (e<sub>i</sub>) ReS<sub>2</sub>-0.4mmol@ZnO-350°C, (e<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-temperature, (e<sub>ii</sub>) ReS<sub>2</sub>-0.3mmol@ZnO-temperature, (b<sub>iii</sub>) <u>ReS<sub>2</sub>-0.4mmol@ZnO-</u>

temperature.



Fig. S3. XRD images of (a<sub>i</sub>) ZnO-80°C, (a<sub>ii</sub>) ZnO-215°C, (a<sub>iii</sub>) ZnO-350°C.



Fig. S4. XRD images of (a) ReS<sub>2</sub>-0.2mmol, ReS<sub>2</sub>-0.2mmol @ ZnO-temperature. (c) ReS<sub>2</sub>-0.4mmol, ReS<sub>2</sub>-0.4mmol @ ZnO-temperature. Growth orientation of (b<sub>i</sub>) ReS<sub>2</sub>-0.2mmol, (b<sub>ii</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-80 °C, (b<sub>iii</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, (b<sub>iv</sub>)ReS<sub>2</sub>-0.3mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, (b<sub>iv</sub>)ReS<sub>2</sub>-0.3mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, (b<sub>iv</sub>)ReS<sub>2</sub>-0.3mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, (b<sub>iv</sub>)ReS<sub>2</sub>-0.3mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-350°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-30°C, (d<sub>i</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-3

0.2mmol, (d<sub>ii</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-80 °C, (d<sub>iii</sub>) ReS<sub>2</sub>-0.2mmol@ZnO-215°C, (d<sub>iv</sub>)ReS<sub>2</sub>-



0.3mmol@ZnO-350°C.

Fig. S5. XRD images of Si substrate.



**Fig. S6.** Energy levels diagram of ReS<sub>2</sub> and ZnO (a). The Gaussian fitted PL emission spectra of ReS<sub>2</sub>-0.2mmol @ ZnO-215 °C (b), ReS<sub>2</sub>-0.3mmol @ ZnO-215 °C (c) and ReS<sub>2</sub>-0.4mmol @ ZnO-215 °C (d).

Table S1. Time of attenuation of transient absorption dynamics

Samples	$ au_1$ (ps)	$ au_2$ (ps)	$ au_3$ (ps)	$ au_4$ (ps)	
ReS <sub>2</sub>	1.89	2.6	$2.2 \times 10^{3}$	-	
ReS <sub>2</sub> @ZnO	0.88	2.67	$1 \times 10^{4}$	$7.3 \times 10^{6}$	